

Proximity-induced diversified magnetic states and electrically-controllable spin polarization in bilayer graphene: Towards layered spintronics

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Compared to monolayer graphene, electrons in Bernal-stacked bilayer graphene (BLG) have an additional layer degree of freedom, offering a platform for developing *layered spintronics* with the help of proximity-induced magnetism. Based on an effective phenomenological model, we systematically study the effect of this magnetism on the spin-dependent band structure near the Fermi energy and identify the magnetic phases induced in BLG by proximity with magnets. We show that spin polarization can develop in BLG due to this proximity effect. This spin polarization depends strongly on the layer distribution of magnetism, and can always be controlled by gate voltage which shifts spin-dependent band edges and modifies the total band gap. We further show that the band spin polarization can be modified by the proximity-induced staggered sublattice potential. By taking full advantage of layer-dependent magnetism in BLG, we propose that spintronic devices such as a spin filter, a giant magnetoresistance device, and a spin diode can operate under fully electric control, which is easier than the common magnetic field control.

I. INTRODUCTION

Bernal-stacked bilayer graphene (BLG) [1] is a van der Waals (vdW) layered two-dimensional (2D) system with the minimum possible layer number [Fig. 1(a)]. It provides an excellent platform to explore exotic phenomena, such as electrically-controllable band gap [2], topological valley Hall effect [3], or superconductivity in a twisted bilayer [4]. The low-energy electrons in BLG are located near two Dirac points K and K' [Fig. 1(b)], referred to as valleys. Isolated ideal BLG is not magnetic [1], however magnetism can be induced by external means, such as magnetic proximity effect [5] or intercalation by magnetic atoms [6], opening the route towards 2D spintronics applications.

Recently, externally induced magnetism in BLG caused considerable attention. In particular, it was theoretically shown that swapping of exchange coupling and spin-orbit coupling [7] and layered antiferromagnetism [8] can be realized using the vdW proximity effect in doubly-proximitized BLG systems. The proximity-induced magnetism results in a significant gate-tunable spin splitting near the Fermi energy, which can reach the order of 10 meV [7–10]. It has been experimentally demonstrated that the spin current is generated via electric and thermal means [5] in BLG with proximity-induced magnetism. Despite this progress, systematic understanding of proximity-induced magnetic states in BLG is still missing.

In this Article, we make the first step towards such understanding by considering magnetism in BLG induced by magnetic materials applied to one or two sides of the BLG sample [Fig. 1(c)]. We only consider materials with out-of-plane magnetization, which can induce ferromagnetic (FM), antiferromagnetic (AFM), or ferrimagnetic (FIM) order in BLG. The out-of-plane magnetization we concentrate on favors ultrahigh-density data storage [11] and is usually superior to the canted or in-plane magnetization [12, 13]. Further considering the ultra-short range nature of the proximity effect [7–10], we reasonably assume that the proximity-induced mag-

netism of two opposite layers of BLG is almost unaffected by the presence of another layer, as rigorously proven by previous first-principles calculations and fitting models [7–10]. This suggests that BLG is an excellent platform to engineer *layered spintronics*, which is proposed here as a separate branch of spintronics due to the independent variability and control of each layer of magnetism. The term “*layered spintronics*” is different from that used in previous works [14–16], which mention “layered spintronics materials” but do not explore the possibility that magnetic structure of every layer can be modified. Encouragingly, the emerging of abundant ultrathin vdW materials [17–21] provides a rich soil for such modifications and thus for the development of *layered spintronics*.

Here, using an effective low-energy phenomenological model, we systematically study the diverse magnetic phases induced by the proximity effect in BLG and obtain the corresponding spin polarization near the Fermi energy. Our results indicate that the band spin polarization depends strongly on the layer distribution of magnetism and can always be controlled by gate voltage by turning on or off spin degeneracy and modulating spin-dependent band edges. We further demonstrate that the spin polarization can be modified by staggered sublattice potential originating from the proximity effect and illustrate how the electrically-tunable spin filtering, giant magnetoresistance, and spin diode effects can be visualized in the devices based on magnetic BLG junctions. The all-electrical control of our proposed devices is superior to the magnetic-field control of traditional devices [22] because the operation is easier. Meanwhile, BLG can be easily integrated into heterostructures [5, 6, 23], and thus our results open new possibilities for developing low-dimensional spin-based devices by fully exploiting the layer degree of freedom.

The organization of this Article is as follows. In Sec. II, we introduce the model Hamiltonian. In Sec. III, we provide and discuss the results for layered magnetism. We conclude in Sec. IV.

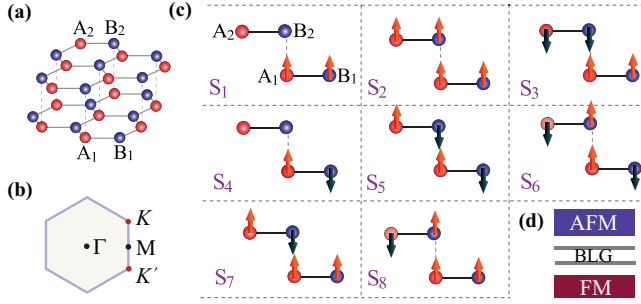


FIG. 1: (a) Bilayer graphene with AB stacking. A_i and B_i ($i = 1, 2$) represent two different sublattices in the i -th layer. (b) Brillouin zone. Γ , M, K and K' label four high-symmetry points. (c) Schematic of eight magnetic states labelled by S_j ($j = 1 \rightarrow 8$) and distinguished by the orientation of magnetic moments of atoms. The atomic arrangement in S_2 to S_8 is the same as that marked in S_1 . Specifically, the atoms in the top layer have no magnetism for S_1 and S_4 . (d) Realization of S_7 or S_8 by magnetic proximity effect from AFM and FM insulators on both sides of BLG.

II. MODEL HAMILTONIAN

Here, we consider BLG where one or both layers are in contact with (generally, different) layers of magnetic materials. In this Section, we construct the low-energy effective Hamiltonian of BLG, assuming that the exchange coupling is sufficiently strong, and the only role of the magnetic layers is to induce magnetism in one or both layers of BLG.

As shown in Fig. 1(a), BLG has four sublattices A_1 , B_1 , A_2 and B_2 , where the subscript 1 (2) marks the bottom (top) layer. Besides charge, the electrons in BLG combine other multiple degrees of freedom [1, 24], including real spin, sublattice pseudospin (in each monolayer), layer pseudospin, and valley, which are described by the Pauli matrices $\mathbf{s} = (s_x, s_y, s_z)$, $\boldsymbol{\sigma} = (\sigma_x, \sigma_y, \sigma_z)$, $\boldsymbol{\tau} = (\tau_x, \tau_y, \tau_z)$, and the index ξ [+1 for valley K and -1 for valley K', see Fig. 1(b)], respectively. The pseudospin $\boldsymbol{\sigma}$ is identical for two monolayers of BLG. Here, we employ \mathbf{I}_s , \mathbf{I}_σ and \mathbf{I}_τ , to denote the identity matrix in the spaces of \mathbf{s} , $\boldsymbol{\sigma}$ and $\boldsymbol{\tau}$, respectively. Taking K (K') as coordinate origin for $\xi = +1$ (-1), the momentum is denoted by $\mathbf{p} = (p_x, p_y)$.

Eight possible magnetic states S_1 to S_8 are shown in Fig. 1(c). In Table I, we summarize the proximity-induced magnetism in graphene materials reported in the existing literature [5–10, 25–38]. It is seen that there have been reports of direct relevance for S_1 to S_4 . For S_5 to S_8 , no direct theoretical or experimental reports have been found yet, however we provide information on the single-interface proximity case, i.e. monolayer graphene/magnetic insulator, as a reference. The configurations S_5 to S_8 become available if we select different magnets on the top and bottom sides. Taking S_7 and S_8 for example, they can be realized by contacting BLG with a ferromagnetic insulator from the bottom side and with an antiferromagnetic insulator from the top side. To study the electronic properties of the heterostructures, we use a simple assumption that the proximity effect only induces magnetism in BLG but does not change the band features of BLG, as

TABLE I: Proximity-induced magnetism in graphene materials reported in the existing literature. Here, S_1 to S_4 correspond to the magnetic states of BLG in Fig. 1. As supplementary information, the hybrid systems composed of monolayer graphene (MLG) and magnetic insulators to realize the FM or AFM states are also listed. The abbreviation CGT stands for $\text{Cr}_2\text{Ge}_2\text{Te}_6$. Note that the hybrid systems BLG/Eu [6] and BLG/CrSBr [5] are magnetized in plane and the others are magnetized out of the plane (without magnetic field). The magnetization is tunable by magnetic field [5, 6].

State	Hybrid systems	Strength (M)	Experiment	Theory
S_1	BLG/CGT	8 meV		[9]
	BLG/Eu	~ 1 meV	[6]	
$S_{2(3)}$	CGT/BLG/CGT	3–10 meV		[8, 10]
	$\text{CrI}_3/\text{BLG}/\text{CrI}_3$	8 meV		[25]
S_4	BLG/CrSBr	~ 20 meV	[5]	
FM	MLG/EuO	~ 36 meV	[26]	[27]
	MLG/EuS	10–100 meV	[28]	[29]
	MLG/ $\text{Y}_3\text{Fe}_5\text{O}_{12}$	~ 80 meV	[30]	[29]
	MLG/ BiFeO_3	30–70 meV	[31]	[32]
	MLG/CGT (Strain)	2.8–13 meV	[33]	[34]
	MLG/ CrI_3 (Strain)	65–150 meV	[35]	[36]
AFM	MLG/ MnPSe_3	~ 0.1 meV		[37]
	MLG/CGT (Twist)	~ 2 meV		[38]

proven previously [6–10, 26–29, 37, 38]. Specifically, the applied vertical pressure in heterostructures [34, 36] is helpful to enhance the proximity-induced magnetism and avoid the introduction of extra orbital hybridization near the Fermi energy of graphene materials. Note that, since the magnets that induce magnetism from the top or bottom side of BLG basically only affect a single layer of BLG close to it, with another graphene layer being largely unaffected [7–10, 38] under the ultra-short range proximity effect, the patterns S_1 to S_8 for the Bernal-stacking situation we consider, the most stable structure and mostly realized in experiments [1–3], are also applicable to the relatively-rare AA-stacking situation [39, 40]. In the atomic basis $\{\psi_{A_1\uparrow}, \psi_{A_1\downarrow}, \psi_{B_1\uparrow}, \psi_{B_1\downarrow}, \psi_{A_2\uparrow}, \psi_{A_2\downarrow}, \psi_{B_2\uparrow}, \psi_{B_2\downarrow}\}$, we establish a generalized phenomenological Hamiltonian as follows,

$$\begin{aligned}
\mathcal{H} = & \mathbf{I}_\tau \otimes v(\sigma_x p_x + \xi \sigma_y p_y) \otimes \mathbf{I}_s \\
& + \frac{\gamma}{2}(\tau_x \otimes \sigma_x - \tau_y \otimes \sigma_y) \otimes \mathbf{I}_s \\
& + M \Sigma_{\tau, \sigma} \otimes s_z \\
& + \Delta \tau_{z, \eta'} \otimes \sigma_z \otimes \mathbf{I}_s \\
& + U \tau_z \otimes \mathbf{I}_\sigma \otimes \mathbf{I}_s \\
& + \mathcal{H}', \\
\mathcal{H}' = & \frac{\lambda_R}{2} \tau_{z, \nu} \otimes (\sigma_x \otimes s_y - \xi \sigma_y \otimes s_x) \\
& + \lambda_I \xi \tau_{z, \chi} \otimes \mathbf{I}_\sigma \otimes s_z.
\end{aligned} \tag{1}$$

The first term H_v indicates the massless Dirac dispersion, where v denotes the Fermi velocity in monolayer graphene. The second term H_γ denotes the interlayer nearest-neighbor coupling, so that $H_v + H_\gamma$ describes the Hamiltonian for bare BLG [1–3]. The third term H_M represents the proximity-induced magnetism. The fourth term H_Δ represents the staggered sublattice potential, which is zero for bare BLG but can appear when BLG is in proximity with other materials

TABLE II: Magnetic type characterized by the parameters $\{\beta, \eta, \zeta\}$. Configurations S_1 to S_8 correspond to those in Fig. 1. The mark “/” indicates that the value is not applicable.

State	$\{\beta, \eta, \zeta\}$	Magnetism Type
S_1	$\{1, 0, /\}$	FM
S_2	$\{1, (0, 1), 1\}$	FM
S_3	$\{1, -1, 1\}$	AFM
S_4	$\{1, (-1, 0), 1\}$	FIM
S_5	$\{-1, 0, /\}$	AFM
S_6	$\{-1, 1, -1\}$	AFM
S_7	$\{-1, (0, 1), -1\}$	FIM
S_8	$\{-1, (-1, 0), -1\}$	AFM
S_9	$\{-1, -1, -1\}$	AFM
S_{10}	$\{-1, (-1, 0), -1\}$	FIM
S_{11}	$\{1, (0, 1), -1\}$	FIM
S_{12}	$\{1, [-1, 0], -1\}$	FIM

[33, 34, 41–49]. The fifth term H_U indicates the interlayer bias (tunable by gate voltage). Without loss of generality, the last term $\mathcal{H}' = \mathcal{H}_R + \mathcal{H}_I$ presents the symmetry-breaking induced perturbations from Rashba-type (λ_R) and Ising-type (λ_I) spin-orbit couplings, which are the most common spin-orbit interactions induced in graphene-based interfaces [7–10, 38]. To describe the dependence of magnetism and staggered sublattice potential on layer and sublattice, we parameterize

$$\Sigma_{\tau, \sigma} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & \beta & 0 & 0 \\ 0 & 0 & \eta & 0 \\ 0 & 0 & 0 & \zeta\eta \end{pmatrix}, \quad \tau_{z, \eta'} = \begin{pmatrix} 1 & 0 \\ 0 & \eta' \end{pmatrix}, \quad (2)$$

where $\tau_{z, \eta'}$ is defined in the τ space, and the dimensionless parameters take the values

$$\{\beta, \zeta\} = \pm 1, \quad \{\eta, \eta'\} \in [-1, 1]. \quad (3)$$

Here, β , η , and ζ are three physical quantities reflecting the relative strength of local magnetism, for which the ratio of exchange splitting on sublattices A_1 , B_1 , A_2 and B_2 is $1 : \beta : \eta : \zeta\eta$. By setting $\beta = \pm 1$ and $\zeta = \pm 1$, we assume for simplicity that the absolute values of magnetization in both sublattices of each monolayer of BLG are the same. The amplitude difference of magnetization between two opposite layers depends on the value of η . Because the proximity effect is short-range, β and η are two completely independent parameters. The index η' depends on the coupling details between BLG and its proximity partners [7–10]. In Table II, we show the magnetic type in the parameter space $\{\beta, \eta, \zeta\}$. Depending on the parameter values, the magnetism types of FM, AFM, FIM are distinguished. To avoid the complexity caused by too many parameters in the model (1), we restrict ourselves below to the qualitative discussion of the effects of the spin-orbit coupling perturbation \mathcal{H}' .

Corresponding to the momentum-space Hamiltonian (1),

the real-space tight-binding Hamiltonian is described as

$$\begin{aligned} H_{\text{TB}} = & -t \sum_{\langle i, j \rangle_{\parallel} \alpha} c_{i\alpha}^\dagger c_{j\alpha} - \gamma \sum_{\langle i, j \rangle_{\perp} \alpha} c_{i\alpha}^\dagger c_{j\alpha} \\ & + \sum_{i\alpha} M_i c_{i\alpha}^\dagger s_z c_{i\alpha} + \sum_{i\alpha} \Delta_i c_{i\alpha}^\dagger c_{i\alpha} \\ & + U \sum_{i\alpha} \mu_i c_{i\alpha}^\dagger c_{i\alpha} + H' \end{aligned} \quad (4)$$

$$\begin{aligned} H' = & \frac{i}{3} \sum_{\langle i, j \rangle, \alpha, \alpha'} \lambda_R^{ij} c_{i\alpha}^\dagger [(s \times d_{ij}) \cdot \hat{z}] c_{j\alpha'} \\ & + \frac{i}{3\sqrt{3}} \sum_{\langle \langle i, j \rangle \rangle, \alpha} \lambda_I^{ij} v_{ij} c_{i\alpha}^\dagger s_z c_{j\alpha} \end{aligned}$$

Here, $c_{i\alpha}^\dagger$ creates an electron with spin polarization α at site i , $\langle i, j \rangle$ ($\ll i, j \gg$) runs over all the (next) nearest-neighbor-hopping sites, and the subscript \parallel (\perp) means in-plane (out-of-plane), α denotes the real spin index, $\mu_i = +1$ (-1) holds if site i locates on the bottom (top) layer, d_{ij} is the unit vector pointing from site j to site i , \hat{z} is the z -axis unit vector, and $v_{ij} = +1$ (-1) is valid for the clockwise (anticlockwise) hopping. The velocity parameter in Hamiltonian (1) is determined by $v = \sqrt{3}at/2\hbar$, where $a = 2.46 \text{ \AA}$ is the lattice constant. The parameter M_i takes the value of M when atom i is located on sublattice A_1 , and the value of βM , ηM , and $\zeta\beta M$ when atom i is located on sublattice B_1 , A_2 , and B_2 , respectively. The parameter Δ_i is Δ if atom i locates on sublattice A_1 or B_1 , and $\eta'\Delta$ if atom i locates on sublattice A_2 or B_2 . By performing Fourier transformation (details are available in Refs. [1, 2]), the real-space Hamiltonian (4) becomes the momentum-space Hamiltonian (1).

In particular, note that we disregard other weaker interlayer hopping terms [1] that are not essential for the problem at hand. Typical parameter values $t = 2.7 \text{ eV}$ and $\gamma = 0.39 \text{ eV}$ [2] are used below to perform all the model calculations. At the same time, we choose for the calculations $M = 10 \text{ meV}$, which is much larger than the ignored band trigonal warping effect (about 1 meV [1] near the neutral point for bare BLG). Variation of these parameters affects the band structures qualitatively but does not change the qualitative conclusions.

III. RESULTS AND DISCUSSION

Since the term H_Δ in Hamiltonian (1) depends on the environment to which BLG is exposed, we divide the situations into the absence (Fig. 2 and Fig. 3) and presence (Fig. 4 and Fig. 5) of H_Δ as below. For each situation, we mainly consider the conduction and valence subbands near the Fermi energy, and discuss in depth the spin polarization, spin-dependent band edges as well as the total band gap. Potential device applications are illustrated at the end of this Section. Note that we have disregarded the spin-orbit coupling $\mathcal{H}' = 0$ in this section; we qualitatively discuss its effects below.

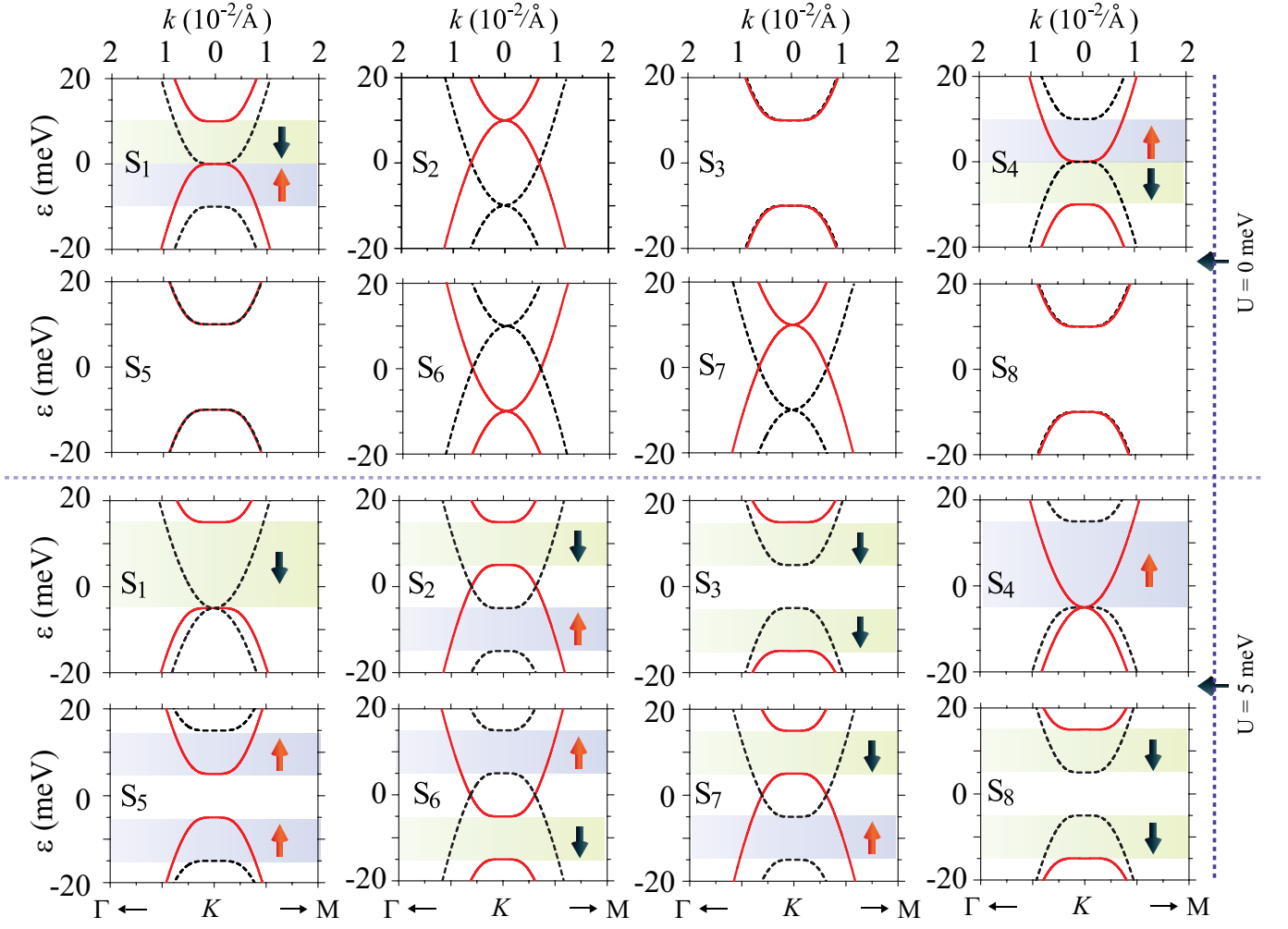


FIG. 2: Band structures for magnetic states S_1 to S_8 in Fig. 1(c). The top (bottom) row indicates the results of $U = 0$ meV ($U = 5$ meV). The red-solid and black-dashed lines correspond to spin-up (\uparrow) and spin-down (\downarrow), respectively. The shaded areas, green for \uparrow and blue for \downarrow , represent the regions of complete spin polarization. The parameters $\Delta = 0$, $M = 10$ meV are fixed. The indices (β, η, ζ) take the values of $(1, 0, /)$ for S_1 , $(1, 1, 1)$ for S_2 , $(1, -1, 1)$ for S_3 , $(-1, 0, /)$ for S_4 , $(-1, 1, -1)$ for S_5 , $(-1, -1, -1)$ for S_6 , $(1, 1, -1)$ for S_7 , and $(1, -1, -1)$ for S_8 .

A. Absence of staggered sublattice potential ($H_\Delta = 0$)

In the top panel of Fig. 2, we show the four low-energy subbands for magnetic states S_1 to S_8 without bias potential ($U = 0$ meV). We fix the parameters $\Delta = 0$ and $M = 10$ meV, and set $|\eta| = 1$ and $|\zeta| = 1$ if η and ζ are nonzero for simplicity. The results for $U = 0$ in Fig. 2 indicate that the spin splitting near the Fermi energy depends strongly on the distribution of magnetism on two opposite layers. For S_1 and S_4 (or for S_2 and S_6), although the band structures of the two together can overlap completely, their band spin polarization is the opposite. For S_2 and S_7 , no band difference is observed. For S_3 , S_5 and S_8 , a band gap is opened, and no spin splitting is observed because all the bands are spin degenerate.

According to the band features shown in Fig. 2, it is reasonable to divide the eight magnetic states (S_1 to S_8) into three types: S_1 and S_4 belong to type-I; S_2 , S_6 , and S_7 belong to type-II; S_3 , S_5 , and S_8 belong to type-III. This classification depends on the fact that the low-energy four bands near the

Fermi energy are basically contributed by sublattices A_2 and B_1 , and the magnetic states in sublattices A_1 and B_2 are trivial. These three types of situations are distinguishable by the value of $\beta\eta$, which is 0 for the type-I case, 1 for the type-II case and -1 for the type-III case. This can be seen from the model: in the case of interest $\{|U|, |M|, |\Delta|\} \ll \gamma$, the eight-band Hamiltonian (1) can be reduced to the following two-band form in the low-energy regime of $\varepsilon < \gamma$ by treating it perturbatively [50],

$$\tilde{\mathcal{H}}_0^s(\mathbf{p}) \simeq \begin{pmatrix} -U + s\eta M & -\frac{v^2}{\gamma}(\pi^\dagger)^2 \\ -\frac{v^2}{\gamma}\pi^2 & U + s\beta M \end{pmatrix}, \quad (5)$$

which takes $\{\psi_{A_2\uparrow}, \psi_{A_2\downarrow}, \psi_{B_1\uparrow}, \psi_{B_1\downarrow}\}$ as the atomic basis. Here, we defined $\pi^\dagger = p_x - ip_y$, and $s = +1$ (-1) denotes spin up (down). Note that the two opposite spin projections are decoupled due to the absence of spin flip. It is seen from Hamiltonian (5) that the index ζ indeed has no influence on the low-energy four subbands, agreeing with the numerical results in Fig. 2, where the difference between S_3 and S_8 (or between S_2

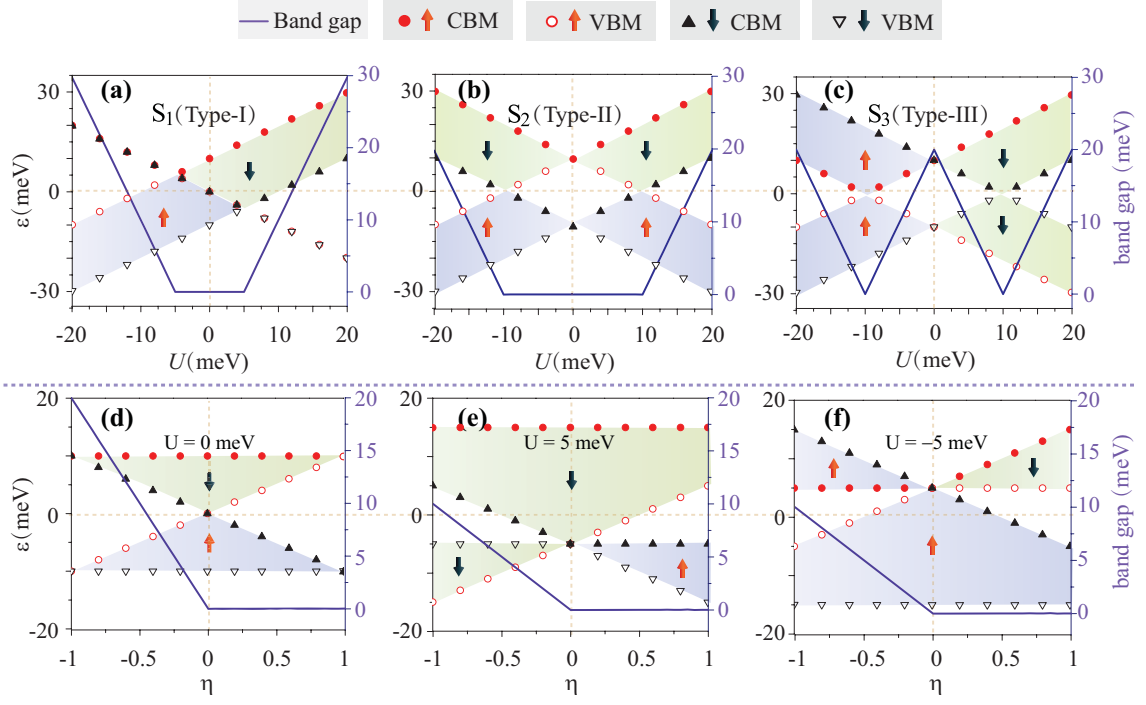


FIG. 3: (a)-(c) Spin-dependent conduction band minimum (CBM) and valence band maximum (VBM), total band gap as a function of bias parameter U for (a) S_1 with $(\beta, \eta) = (1, 0)$, (b) S_2 with $(\beta, \eta, \zeta) = (1, 1, 1)$ and (c) S_3 with $(\beta, \eta, \zeta) = (1, -1, 1)$. (d)-(f) Dependence of spin-dependent CBM and VBM, the total band gap on layer polarization parameter η for (d) $U = 0$, (e) $U = 5$ meV and (f) $U = -5$ meV for $(\beta, \zeta) = (1, 1)$. In (a)-(f), the parameters $\Delta = 0$ and $M = 10$ meV are fixed, and the shadows (blue for spin up and green for spin down) represent the regions of complete spin polarization in the (ϵ, U) plane.

and S_7) is indeed invisible.

In the bottom panel of Fig. 2, we show the band results for S_1 to S_8 by fixing the gate voltage parameter $U = 5$ meV. It is shown that the spin splitting for each magnetic state is modulated by gate voltage. For the type-I case, the band region of complete spin-down polarization is increased while that of complete spin-up polarization is reduced. For the type-II case, the band region of full spin polarization is opened. For the type-III case, the total band gap is reduced and the two conduction and valence subbands closest to the Fermi energy have isospin polarization, which is different from the behavior in the type-I and type-II cases. The numerical results are consistent with the analytical expression

$$\epsilon_0^s = \frac{\beta + \eta}{2} sM \pm \sqrt{\frac{\nu^4}{\gamma^2} p^4 + \left(U + \frac{\beta - \eta}{2} sM \right)^2}, \quad (6)$$

produced by the diagonalization of Hamiltonian (5). Here, \pm correspond to the conduction (valence) band.

We further show the influence of gate voltage (U) on the band structure in the top panel of Fig. 3, where the information on spin-dependent conduction band minimum (CBM) and valence band maximum (VBM) as well as the total band gap can be extracted. Because the same-type magnetic states (type-I, type-II or type-III) exhibit similar gate-tunable band features, S_1 (type-I), S_2 (type-II), and S_3 (type-III) are chosen as the representative of the same type to perform calculations. By analyzing the evolution of band edges as U varies, we iden-

tify the band regions of full spin polarization, as shown by the shaded areas. It is found that the spin splitting near the Fermi energy is always controllable by gate voltage through turning on or off or even flipping spin polarization near the Fermi energy as well as via modulation of the spin-dependent band gap. Two band features are identified: (i) gate voltage induces the electron-hole asymmetry for S_1 (type-I), in sharp contrast to S_2 (type-II) and S_3 (type-III); (ii) the opposite gate voltages ($\pm U$) do not change the energy band structure for S_2 (type-II) but reverse the orientation of band spin polarization for S_3 (type-III).

In the bottom panel of Fig. 3, we show the influence of the layer polarization index η on spin-dependent CBM/VBM and on the total band gap. The cases of $U = 0, \pm 5$ meV are shown. As η varies, the electron-hole symmetry is preserved for $U = 0$ but is broken for $U = \pm 5$ meV. It is found that the value of η influences the width of the complete spin polarization regions because the difference in magnetic properties between two opposite layers is modified by η .

Additionally, we argue that both spin-orbit interaction terms in \mathcal{H}' inevitably affect the band characteristics or even the electronic topological properties [7–10]. In our latest theoretical work [50], the analytical processes related to spin-orbit coupling and magnetism in BLG are discussed in detail (due to the complexity of the expressions, we do not show them here). In particular, the sign of ν and χ in \mathcal{H}' is more likely to be negative [10, 23, 50] due to structural symmetry in real doubly-proximitized BLG samples.

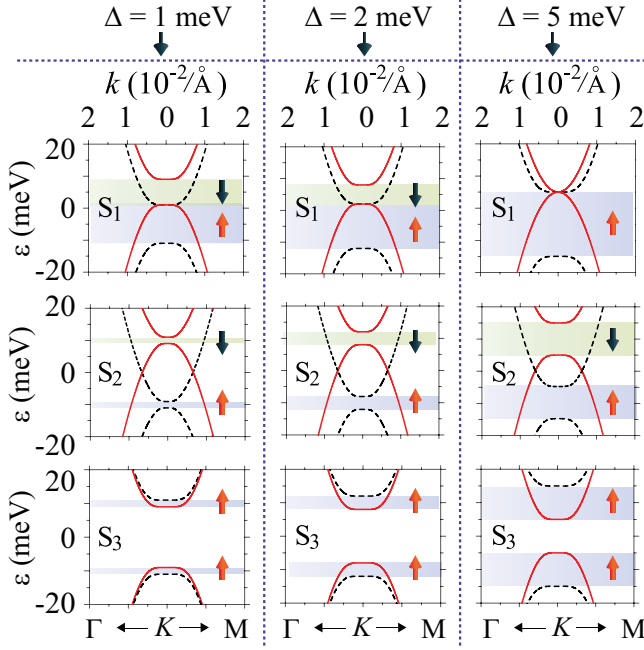


FIG. 4: (a)-(c) Dependence of CBM and VBM for spin up and spin down and the total band gap on the bias parameter U for S_1 , S_2 and S_3 in Fig. 1(c). The parameters take the same values as those used in Fig. 2, except that $\Delta = 5$ meV and $\eta' = 1$.

B. Influence of staggered sublattice potential ($H_\Delta \neq 0$)

In Fig. 4, we show the influence of the staggered sublattice potential (Δ) on the band structures (Fig. 2) for S_1 , S_2 , and S_3 without gate voltage. For comparison, the three cases $\Delta = 1$ meV, 2 meV and 3 meV are shown. Our results indicate that the band spin polarization is modified by Δ . As Δ increases from 1 meV to 3 meV, the energy range of full spin-up (spin-down) polarization gets wider (narrower) for S_1 ; the energy ranges of full spin polarizations for both spin-up and spin-down become wider for S_2 ; the total band gap decreases and the energy range of full spin-up polarization becomes larger while complete spin-down polarization is absent for S_3 . Consequently, the value of Δ directly affects the energy range in which full spin polarization is observed.

Since the case of spin polarization should be revised according to the environment to which BLG is exposed, the corresponding spin-decoupled two-band Hamiltonian revised by Δ reads

$$\tilde{\mathcal{H}}_s(\mathbf{p}) \approx \tilde{\mathcal{H}}_0^s(\mathbf{p}) + \begin{pmatrix} \eta' \Delta & 0 \\ 0 & -\Delta \end{pmatrix}. \quad (7)$$

Here, we can split the second term $\tilde{\mathcal{H}}_\Delta$ into two terms: one is the Fermi-energy correction term $(\eta' \Delta - \Delta)/2$ and the other is $(\eta' \Delta + \Delta)\tilde{\sigma}_z/2$, where $\tilde{\sigma}_z$ is the z component of Pauli matrix in the $\{B_2, A_1\}$ sublattice space. When $\eta' = -1$ holds, Δ merely shifts the Fermi energy.

By fixing the staggered sublattice potential $\Delta = 5$ meV and the index $\eta' = 1$, we further show the influence of U on the spin-dependent VBM and CBM as well as the total band gap

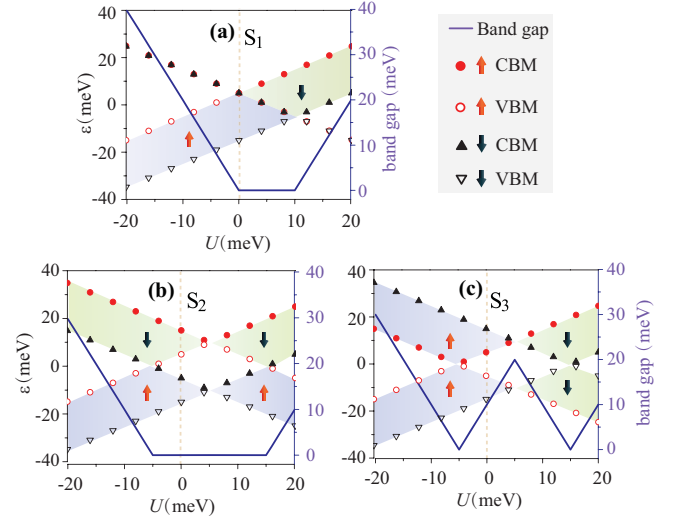


FIG. 5: (a)-(c) Dependence of CBM and VBM for spin up and spin down and the total band gap on bias parameter U for S_i in Fig. 1(c). The parameters take the same values as those used in Fig. 2, except that $\Delta = 5$ meV and $\eta' = 1$.

in Fig. 5. After analyzing the evolution of band edges as U changes, we identify the energy ranges of bands with full spin polarization, as shown by the shaded areas. Comparing the results of Fig. 5 and Fig. 3 (top), we see that the data in Fig. 5 is the result of all the data in Fig. 3 being shifted by 5 meV to the right along the U axis. In this sense, $\Delta = 5$ meV is equivalent to the gate voltage $U = -5$ meV. The band structure corresponding to the Hamiltonian (7) is

$$\begin{aligned} \epsilon^s &= \frac{\beta + \eta}{2} sM + \frac{\eta' - 1}{2} \Delta \pm \sqrt{\frac{v^4}{\gamma^2} p^4 + \Omega^2}, \\ \Omega &= \frac{\beta - \eta}{2} sM - \frac{\eta' + 1}{2} \Delta, \end{aligned} \quad (8)$$

agreeing well with the above numerical results.

We also remark here that the band structure of bilayer graphene is very sensitive to the stacking order, which determines the structural symmetry. Specifically, the case of AA-stacking (inversion and mirror symmetry) has higher symmetry than that of Bernal-stacking (inversion symmetry) in terms of the spatial structure, leading to a parabolic dispersion for Bernal stacking but a Dirac dispersion for AA-stacking [39]. Nevertheless, we expect that the phenomena related to electrically-controllable spin polarization would be qualitatively similar for Bernal and AA-stacking situations. Quantitative treatment of the band structure for the AA-stacking would require an inclusion of strong Coulomb interaction [51].

C. Potential device applications

Our results in Figs. 2-5 reveal that each magnetic state, S_1 to S_8 , in Fig. 1(c) is capable of exhibiting the complete band

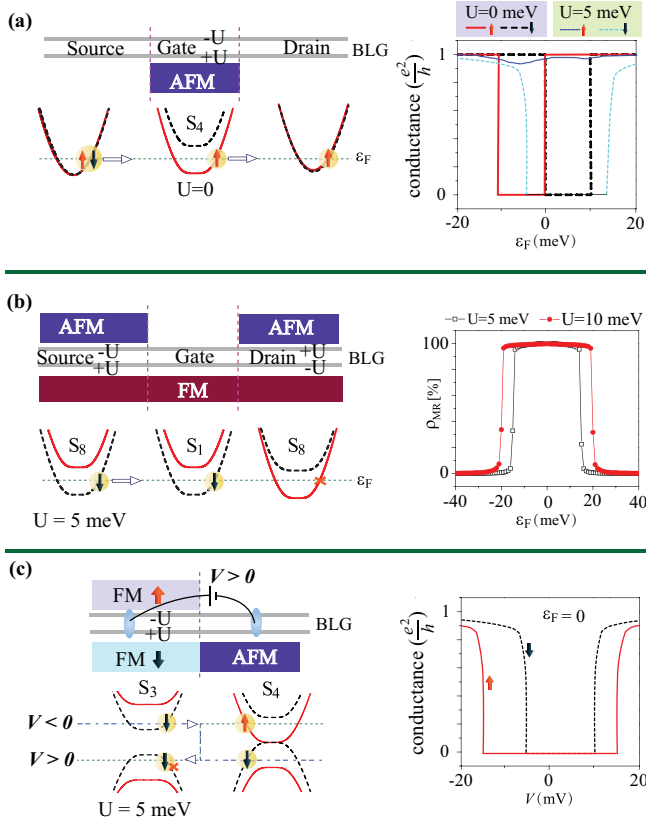


FIG. 6: Proposed spintronic devices for (a) spin filtering effect, (b) giant magnetoresistance effect, and (c) spin diode effect under the mechanism of band-to-band spin-matching tunneling. Among the many choices in Fig. 1(c), only S_4 in (a), S_1+S_8 in (b), and S_3+S_4 in (c) are taken as examples. Here, ε_F denotes the Fermi energy, and “ \times ” indicates no transmission. The gate voltage parameter $\pm U$ in (a)–(c) can be induced by dual gates [3], and V in (c) is a longitudinal bias. The right panels in (a) and (b) show the calculated results for an armchair-edged BLG, for which the width in (a)–(c) is set as 9.84 nm and the gate-region length in (a) and (b) is fixed at 8.52 nm [a sharp interface [2] is considered for simplicity in (c)], while other parameters are consistent with Fig. 2.

spin polarization by tuning gate voltage. This offers a multitude of options for designing spintronic devices by making full use of the layer degree of freedom in BLG. We quantitatively investigate some interesting situations below.

By using quantum transport theory [2, 8], the zero-temperature conductance in a two-terminal device is expressed as

$$G = \frac{e^2}{h} \mathcal{T}(\varepsilon), \quad (9)$$

where $\mathcal{T}(\varepsilon) = \text{Tr}(\mathcal{G}\Gamma_1\mathcal{G}^\dagger\Gamma_2)$ is the transmission coefficient, \mathcal{G} is the Green’s function of the system, Tr denotes the trace, and $\Gamma_{1,2} = i(\Sigma_{1,2} - \Sigma_{1,2}^\dagger)$ is the broadening of two electrodes.

In the left panel of Fig. 6(a), the spin filtering effect is realized in a normal/ S_4 /normal junction, where “normal” represents the normal bare BLG. Such a junction can be experimentally prepared by locally contacting a bare BLG sample

with an AFM material. Due to the short-range property of magnetic proximity effect, it is reasonable to assume that the top layer has no magnetism, while the bottom layer has the spatial nonuniform magnetism. The layer-contrasting mechanism here leads to the result that spin-up electrons take part in conduction while transport of spin-down electrons from the source (electrode 1) to the drain (electrode 2) is blocked for $U = 0$ since the band-to-band tunneling must be spin matching. The conductance in this device is shown in the right panel of Fig. 6(a). For $U = 0$, spin up is conductive but spin down is blocked for $\varepsilon_F \in (0, 10 \text{ meV})$, while spin down is conducting but spin up is blocked for $\varepsilon_F \in (-10 \text{ meV}, 0)$, agreeing with the band analysis under the selected parameters. For $U = 5 \text{ meV}$, spin up is conducting but spin down is blocked for $\varepsilon_F \in (-5 \text{ meV}, 15 \text{ meV})$, because U modifies the band spin polarization in the central scattering region (gate).

In the left panel of Fig. 6(b), an $S_8/S_1/S_8$ junction is investigated as a giant magnetoresistance device. This junction can be prepared by contacting the whole bottom layer of a BLG sample with a FM insulator and at the same time contacting the two electrodes on the top layer with an AFM insulator. Based on Eq. (9), the electrically-controllable MR effect is characterized by the ratio [8]

$$\rho_{\text{MR}} = \frac{R_{\text{AP}} - R_{\text{P}}}{R_{\text{AP}} + R_{\text{P}}}, \quad (10)$$

where $R = 1/G$ is the resistance, and the subscript AP (P) indicates the antiparallel (parallel) alignment of the gate voltages on both electrodes. The dependence of ρ_{MR} on the Fermi energy is plotted in the right panel of Fig. 6(b), where we used the values $U = 5 \text{ meV}$ and 10 meV . In this case, the AP (P) configuration corresponds to the high (low) resistance state. Determined by the band-to-band spin-matching tunneling mechanism, nearly 100% magnetoresistance effect is observed for $\varepsilon_F \in (-15 \text{ meV}, 15 \text{ meV})$ at $U = 5 \text{ meV}$ and for $\varepsilon_F \in (-25 \text{ meV}, 25 \text{ meV})$ at $U = 10 \text{ meV}$.

In Fig. 6(c), we illustrate that a spin diode effect — a fully spin-polarized current which is flowing in the forward direction and blocked in the backward direction (or vice versa) [52, 53] — can be realized in an S_3/S_4 junction. This junction can be prepared in a BLG sample that is doubly proximitized by two reverse-magnetized FM insulators (one is at the top, the other is at the bottom) on the left region of BLG and by one bottom AFM insulator on the right region of BLG. For the calculations (right panel), we fix $U = 5 \text{ meV}$ in the S_3 region. We demonstrate that, for the longitudinal bias $5 \text{ mV} < |V| < 10 \text{ mV}$, spin down is conductive for negative bias but blocked for positive bias, while spin up is always blocked, agreeing well with the spin-matching tunnelling analysis of spin diode effect (left panel). For $|V| < 5 \text{ mV}$, no current is generated for any spin direction due to the presence of band gap in the S_3 region. For $|V| > 10 \text{ mV}$, the spin diode effect disappears because more subbands participate in transport. Specifically, the result of $U = 0$ in Fig. 6(c) is not plotted here because the spin diode effect is absent.

Note that Fig. 6 shows just three examples of spintronic devices based on layer-contrasting magnetism in BLG. In principle, the spin-filtering effect or the giant magnetoresistance

effect can be realized for many combinations from S_1 to S_8 under the control of gate voltage, revealing the appeal of *layered spintronics* — by tuning the layer degree of freedom we can design devices with various operational principle.

To develop layered spintronics based on the nonmagnetic BLG or other possible 2D materials [17–21], the key is to find its suitable magnetic-proximity partners which do not significantly affect the electron structure of the parents. Despite the existence of many early reports in Table I, a lot of efforts are still needed in the near future, specifically in the exploration of room-temperature magnetism. Beyond the nonmagnetic 2D materials, looking for intrinsic vdW magnets or heteromagnets with high Curie or Néel temperature [54, 55] provides an alternative way to develop layered spintronics.

IV. CONCLUSIONS

In this Article, we have shown how layer-dependent magnetism, induced in bilayer graphene via the magnetic proximity effect when it is brought in contact with various magnetic materials on one or both sides, affects the electron band structure. We considered the cases of ferro-, antiferro-, and ferromagnetism. In particular, we have discovered that the spin polarization near the Fermi energy depends strongly on the magnetic configuration of BLG. Significantly, the spin polarization can be tuned by gate voltage which shifts the edges of spin-dependent bands and alters the total band gaps. In addition, the spin polarization can be modified by the proximity-induced staggered sublattice potential.

Our main assumption here is that the magnetic structure of the graphene layer in contact with magnetic material (with possible further restrictions as only certain magnetic planes, such as FM Fe(111) plane in AFM BiFeO₃ [31, 32] could be

efficient) repeats this magnetic material, or, in other words, that the magnetic proximity effect is (i) complete and (ii) does not cause back-action and does not modify the magnetic structure of the proximity material due to the presence of graphene. Existing experimental studies [5] are consistent with these two assumptions, however, more research is needed to understand their limitations and the role of back-action. We furthermore disregarded the influence of dipole-dipole interactions on proximity-induced magnetism. We know that in 2D vdW magnets the situation can be even more complicated. For example, FePS₃ is a layered antiferromagnet with zigzag ordering (see e.g. Ref. [56]), and for emergence of the zigzag order second- and third-nearest-neighbor exchange interactions are essential. It would be interesting to expand our research to include other types of interactions, relevant to a broader class of vdW materials.

Based on our findings, in particular, of the gate-voltage controlled regimes of full spin polarization, we proposed specific devices based on bilayer graphene — spin filter and giant magnetoresistance, which are fully electrically controlled. They make a full use of the layer degree of freedom, with the advantage of easiness of operation compared with the magnetic field control. This is only the beginning of the research on layered spintronics, and we expect that further research will uncover other interesting and useful effects and applications.

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